



Article

Room Temperature Processed Double Electron Transport Layers for Efficient Perovskite Solar Cells

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Abstract: Zinc Oxide (ZnO) has been regarded as a promising electron transport layer (ETL) in perovskite solar cells (PSCs) owing to its high electron mobility. However, the acid-nonresistance of ZnO could destroy organic-inorganic hybrid halide perovskite such as methylammonium lead triiodide (MAPbI₃) in PSCs, resulting in poor power conversion efficiency (PCE). It is demonstrated in this work that Nb₂O₅/ZnO films were deposited at room temperature with RF magnetron sputtering and were successfully used as double electron transport layers (DETL) in PSCs due to the energy band matching between Nb₂O₅ and MAPbI₃ as well as ZnO. In addition, the insertion of Nb₂O₅ between ZnO and MAPbI₃ facilitated the stability of the perovskite film. A systematic investigation of the ZnO deposition time on the PCE has been carried out. A deposition time of five minutes achieved a ZnO layer in the PSCs with the highest power conversion efficiency of up to 13.8%. This excellent photovoltaic property was caused by the excellent light absorption property of the high-quality perovskite film and a fast electron extraction at the perovskite/DETL interface.

Keywords: perovskite; interface; double electron transport layer; energy band matching; electron transport



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1. Introduction

Organic-inorganic hybrid halide perovskites CH₃NH₃PbX₃ (X=I, Br, or Cl) are very promising materials in perovskite solar cells (PSCs) owing to their tunable direct bandgap [1], high light absorption coefficient [2], excellent carrier mobility [3] and long carrier diffusion length [4]. However, there are a few limitations for the applications of these PSCs [5]. For example, the perovskite materials can break down due to the influence of the ambient environment such as heat, moisture and nearby materials [6,7]. The preparation of the electron transport layer (ETL) in PSCs when using materials such as TiO₂ requires high temperature annealing [8]. This has prevented the development of PSCs as a promising future clean energy. In recent years, many researchers have worked on PSCs to solve these challenges [9–12].

The PSCs usually have “p-i-n(n-i-p)” type planar sandwiched structures, where “p” is the hole transport layer (HTL), “i” is the intrinsic light absorption layer (perovskite) and “n” is the ETL [13,14]. There are many candidate materials such as TiO₂ and ZnO for the ETL in PSCs [15–18]. By contrast, the temperature required for the deposition of ZnO for the ETL is notably lower than that of a TiO₂ mesoporous film. Furthermore, the electron mobility of ZnO is substantially higher than TiO₂. These advantages make ZnO

an ideal choice for the ETL [19]. However, studies have effectively demonstrated that organic-inorganic hybrid halide perovskite MAPbI₃ may be degraded into PbI₂ if MAPbI₃ is directly deposited on ZnO, accompanied by the appearing of a yellow color [20–22]. This phenomenon was also found in the current work as shown in the left part of Figure 1. The MAPbI₃ film decomposed into a yellow-colored byproduct for the case of MAPbI₃/ZnO. This was caused by the basic nature of the ZnO surface [20], which led to deprotonation of the methylammonium cation and the formation of PbI₂. The process could be accelerated by the presence of surface hydroxyl groups and/or residual acetate ligands. The efficiency was then expected to be extremely low or zero after the decomposition of MAPbI₃ in the PSCs. To overcome this drawback, Cao et al. [23] modified the surface of ZnO using MgO and ethanolamine in the PSCs. This improved the performance of the PSCs while the energy band of MgO and ZnO as well as perovskite was not matched. Zuo and co-workers [24] deposited 3-aminopropanoic acid SAM (C3-SAM) onto sol–gel ZnO layers and induced a significant improvement in the morphology of the perovskite film. However, the annealing temperature for the ZnO film of 160 °C in this spin-coating method limited its application in many areas.

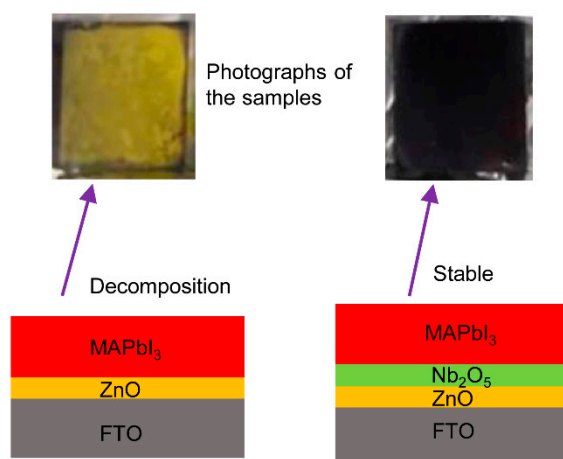


Figure 1. Photographs of MAPbI₃ film on ZnO (left) and Nb₂O₅/ZnO (right).

Previously, Nb₂O₅ was used to modify ZnO in the study of dye-sensitized solar cells and exhibited compatibility between Nb₂O₅ and ZnO [25]. This indicated the possibility of using Nb₂O₅ /ZnO as the double electron transport layer (DETL) in MAPbI₃-based solar cells. Firstly, Nb₂O₅ can be prepared by many methods at room temperature with low cost and through simple processes [26–29]. Secondly, the conduction band of Nb₂O₅ is between ZnO and MAPbI₃ [30,31], which enables the rapid injection of electrons from the perovskite layer into the ZnO and bottom electrode. Furthermore, the insertion of Nb₂O₅ can prevent the chemical decomposition of MAPbI₃ caused by ZnO. MAPbI₃ films deposited directly onto a Nb₂O₅/ZnO DETL showed no changes in its color (dark brown) as shown in the right part of Figure 1. This indicated that the insertion of Nb₂O₅ prevented chemical decomposition and improved the stability of the perovskite film. This finding motivated our study of ultra-thin Nb₂O₅/ZnO films as a promising DETL used in PSCs.

With the above consideration, in this work we deposited Nb₂O₅/ZnO thin films at room temperature with a magnetron sputtering technique to create efficient and stable PSCs [32]. In the fabricated solar cells, Nb₂O₅/ZnO thin films were adopted as the DETL. The PCE of PSCs based on Nb₂O₅/5-ZnO (a ZnO deposition time of five minutes) thin film was found to reach the highest efficiency of 13.8%. The room temperature processing and relatively high device performance suggest great potential for Nb₂O₅/ZnO thin films as the DETL in applications such as large area solar cells and other optoelectrical devices.

2. Experimental Section

2.1. Materials Preparation

All of the solvents were purchased from Sigma-Aldrich. MAI (99.99%), PbI_2 (99.99%) and Spiro-OMeTAD (99.8%) were purchased from Xi'an Polymer Light Technology Corp (Xi'an, China). Nb_2O_5 and ZnO target materials were purchased from Hebei Qinbang New Material Technology Co. Ltd (Handan, China). Fluorine tin oxide (FTO) glass was purchased from Nippin Sheet Glass Co. Ltd (Minato, Japan). A MAPbI_3 precursor solution was formed through dissolving 159 mg methyl ammonium iodine (MAI) and 480 mg PbI_2 in 800 μL of a solution of dimethyl sulfoxide (DMSO) and *N,N*-dimethylformamide (DMF) (volume ratio of DMSO to DMF was 1:4). The precursor solution of Spiro-OMeTAD for the hole transport layer was formed by dissolving 72.3 mg Spiro-OMeTAD in 1 mL chlorobenzene. In sequence, 17.5 μL acetonitrile solution of Lithium bis(trifluoromethylsulphonyl)imide (LiTFSI) (520 mg/mL) and 28 μL 4-tert-butylpyridine were added to the resulting solution.

2.2. Deposition of $\text{Nb}_2\text{O}_5/\text{ZnO}$ Films

ZnO thin films were deposited at room temperature by RF magnetron sputtering in an argon (99.999%) atmosphere using a pure ZnO target (99.99%). Initially, the vacuum was pumped to 10^{-4} Pa and the target was exposed to pure Ar and oxygen gas (purity 99.999%) with a flow rate of 60 sccm and 1 sccm, respectively. This led to a chamber pressure of 0.5 Pa. The distance between the substrate and ZnO target was 20 cm and the sputtering power was set to 60 W. The substrate rotation speed was 2 rad/s. A baffle plate over the ZnO target was closed and the target was pre-sputtered for four minutes to remove dust and impurities. ZnO films were then deposited by opening the baffle plate to expose the substrate to the target for a set time before again closing the baffle. The films' thickness was varied under a deposition time of three, five and eight minutes, respectively.

Nb_2O_5 thin films were prepared at room temperature with RF magnetic sputtering in an argon (99.999%) atmosphere using a pure Nb_2O_5 target (99.999%). Before sputtering, the vacuum was pumped to 10^{-4} Pa. The target was then exposed to pure argon and oxygen gas with a flow rate of 20 sccm, leading a chamber pressure of 0.3 Pa. The distance between the substrate and the Nb_2O_5 target was 20 cm and the sputtering power was 50 W. The substrate rotation speed was 2 rad/s. The baffle plate of Nb_2O_5 target was closed in the beginning and the target was pre-sputtered for four minutes to remove dust and impurities. The substrate baffle of the target was then opened and an ultra-thin Nb_2O_5 film was obtained after two minutes' sputtering. Finally, $\text{Nb}_2\text{O}_5/\text{ZnO}$ DETLs were formed.

2.3. Device Fabrication

The fluorine-doped tin oxide (FTO) glass substrates (1.45 cm \times 1.45 cm) were firstly ultra-sonically cleaned with deionized water, acetone and ethanol for 15 minutes, respectively. These substrates were then treated with UV-ozone for 20 minutes. The $\text{Nb}_2\text{O}_5/\text{ZnO}$ thin films for DLET were deposited onto the substrates by the method described above. A MAPbI_3 precursor solution was subsequently spin-coated on the ETL to form perovskite MAPbI_3 films through a one step process, which included two-speed steps (i.e., 500 rpm for 3 s followed by 4000 rpm for 20 s). During the second step, about 300 μL of chlorobenzene was added by dropping after 10 s spin-coating. The device was then annealed in an N_2 atmosphere at 75 $^\circ\text{C}$ for 10 minutes followed by a second 10 minutes' annealing at 105 $^\circ\text{C}$. After annealing, a Spiro-OMeTAD solution was spin-coated at 3000 rpm for 30 s. Finally, 150 nm thick silver electrodes were prepared by thermal evaporation under a 10^{-5} bar vacuum condition.

2.4. Characterization

Elements of Zn and Nb were verified using the X-ray photoelectron spectroscopy analyzer (AXIS Supra) with a monochromatic Al $K\alpha$ X-ray source. Surface morphologies of the perovskite films were measured by scanning electron microscopy (SEM, FEI NOVA Nano SEM 450). X-ray diffraction (XRD) patterns were analyzed by an X-ray diffractometer

(Bruker D8 Advance, Ettlingen, Germany) with a Cu-K α radiation source ($\lambda=1.5418 \text{ \AA}$). The absorption spectra were measured with an UV-Vis spectrophotometer (PerkinElmer Lambda 650 S, Nanjing, China) in the range from 450 to 800 nm. The current voltage (J-V) characteristics were obtained at a solar simulator (AM 1.5 G, 100mWcm^{-2} , Newport 91150, USA) equipped with a Keithley 2400 source meter. The incident photon-to-electron conversion efficiency (IPCE) of the devices was characterized on a computer-controlled IPCE system (Newport). The electrochemical impedance spectroscopy (EIS) was measured under a positive bias of 1 V, with an amplitude of 0.01 V and a frequency range from 1 Hz to 1 MHz. The photoluminescence spectra (excitation at 485 nm) were recorded by an Edinburgh F900.

3. Results and Discussion

The planar PSCs with a DETL were fabricated as shown in Figure 2a. The schematic of the energy band alignment is shown in Figure 2b. In the fabricated PSCs, the electrode FTO was used as the bottom cathode and Spiro-OMeTAD and Ag as the HTL and top anode, respectively. MAPbI₃ was used as the optically active layer. ZnO was used as the ETL. The ZnO/perovskite interface was mediated by a thin layer of Nb₂O₅. Such an interfacial structure plays two important roles: (1) the Nb₂O₅ film stopped the MAPbI₃ from reacting with the ZnO. This was confirmed visually in Figure 1. (2) The ultra-thin Nb₂O₅ film was beneficial to the electron transport at the interfaces due to the matching of the energy band structure as shown in Figure 2b [33–35]. Thus, Nb₂O₅/ZnO films were used as the DETL in this study. The carrier transport process in the device is explained by the following process. Electron hole pairs were generated in response to external light exposure. Under the driving force of the built-in electric field at the interfaces between perovskite and transport layers, the holes were transferred into the Ag electrode through Spiro-OMeTAD while electrons were rapidly injected into the Nb₂O₅/ZnO layers from the MAPbI₃ [34].

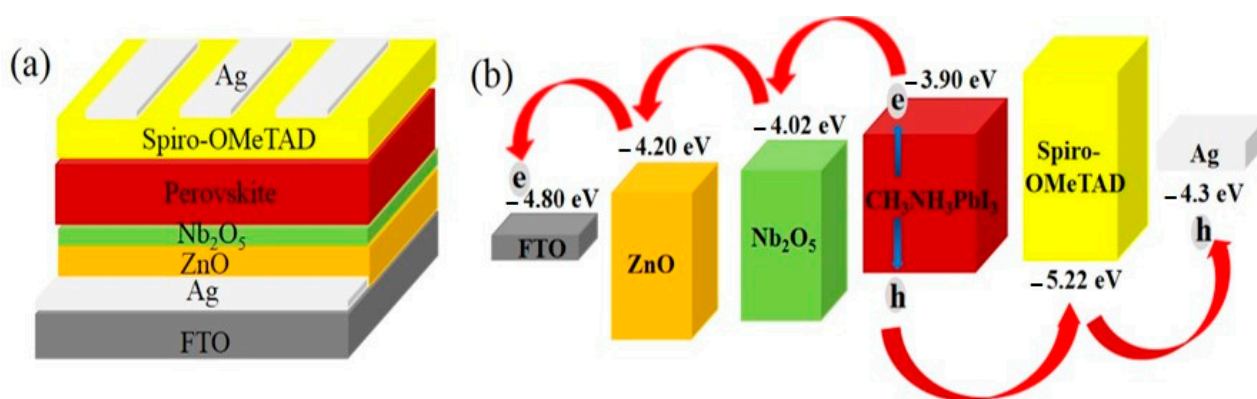


Figure 2. (a) Schematics of the planar perovskite solar cells (PSCs) based on an Nb₂O₅/ZnO thin film, (b) Energy band alignment of the devices.

The double Nb₂O₅/ZnO electron transport layers were deposited on an FTO glass substrate with magnetron sputtering. During this process, the films' thicknesses could be obtained using a quartz crystal thickness monitor [36]. Considering the accuracy limitations of the quartz crystal thickness monitor in determining the ultra-thin films in the current work, the thickness of the ZnO and Nb₂O₅ films was then determined, respectively, based on the obtained deposition rates by controlling the deposition times. The deposition rates of these films with current experimental procedures were previously estimated in the same lab. In the current work, the deposition time for Nb₂O₅ was five minutes and the thickness was then estimated to be ~15 nm. The deposition time of the ZnO films was three minutes (Nb₂O₅/3-ZnO), five minutes (Nb₂O₅/5-ZnO) and eight minutes (Nb₂O₅/8-ZnO), respectively. Their thicknesses corresponded to 12 nm, 20 nm and 32 nm accordingly. This

is similar to the way of, for example, Nb-doped TiO_{2-x} film (used as an electrode and ETL) thickness control through adjusting the deposition time in a perovskite solar cell in the work of Kim et al. [37]. However, the film thickness (300 nm) was measured using a transmission electron microscope technique in their work. To confirm the presence of Nb_2O_5 and ZnO films on the FTO, the electronic states of the deposited ZnO and $\text{Nb}_2\text{O}_5/\text{ZnO}$ films were characterized by XPS spectra. Figure 3a shows a high resolution XPS spectrum of the Zn 2p in the ZnO thin film. It can be clearly seen that there were two peaks located at the binding energies of 1019.5 eV and 1042.5 eV, which corresponded to Zn $2p_{3/2}$ and Zn $2p_{1/2}$, indicating the existence of divalent zinc. This meant the ZnO thin film was successfully covered on the FTO glass substrates. Figure 3b shows the high resolution XPS spectrum of Nb 3d in the $\text{Nb}_2\text{O}_5/\text{ZnO}$ thin film. It shows double peaks at the positions of binding energy of 205.0 eV and 207.7 eV, corresponding to Nb $3d_{5/2}$ and Nb $3d_{3/2}$, respectively, demonstrating the existence of pentavalent niobium. This confirmed that ultra-thin Nb_2O_5 thin films were deposited on ZnO thin films completely. Therefore, these findings indicated that an $\text{Nb}_2\text{O}_5/\text{ZnO}$ DETL was successfully deposited on the glass substrate.

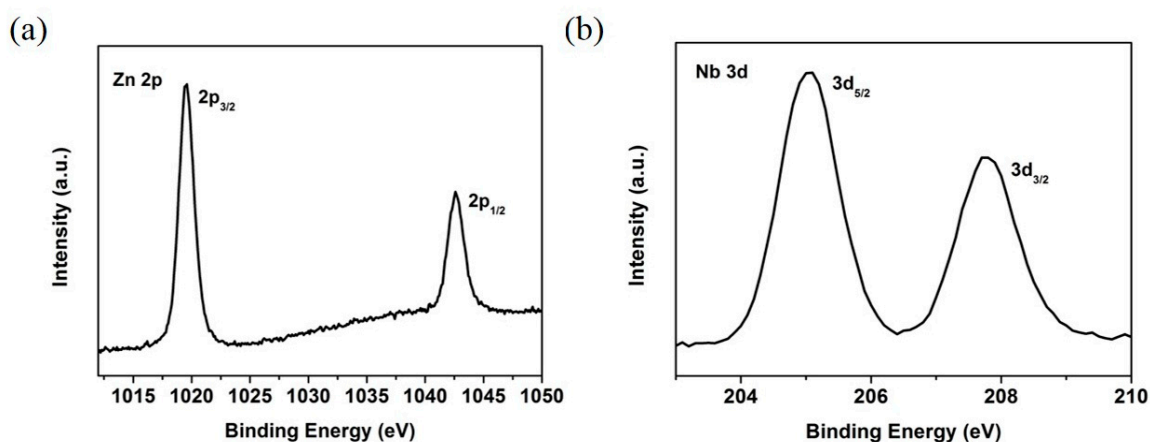


Figure 3. (a) Zn 2p high resolution XPS spectrum of ZnO thin film; (b) Nb 3d high resolution XPS spectrum of $\text{Nb}_2\text{O}_5/\text{ZnO}$ thin film.

The MAPbI_3 film was spin-coated onto the DETL. The optical absorption properties of the perovskite film were investigated using the UV-Vis spectroscopy. The results are presented in Figure 4. The perovskite film on $\text{Nb}_2\text{O}_5/5\text{-ZnO}$ revealed a stronger light absorption property than that of $\text{Nb}_2\text{O}_5/8\text{-ZnO}$. The absorption property was the worst in the film based on $\text{Nb}_2\text{O}_5/3\text{-ZnO}$. This trend could be related to the improvement of the crystallizing quality of the perovskite film based on the different ETLs in the order of $\text{Nb}_2\text{O}_5/3\text{-ZnO} \rightarrow \text{Nb}_2\text{O}_5/8\text{-ZnO} \rightarrow \text{Nb}_2\text{O}_5/5\text{-ZnO}$ from the XRD patterns (Figure S1). The bandgap of ZnO was around 3.2 eV. This indicated that a thin ZnO film was transparent to the wavelength of light larger than 387 nm and could be excluded for the causes of observed difference of light absorption [38].

The current density versus voltage (J-V) curves of the PSCs based on $\text{Nb}_2\text{O}_5/3\text{-ZnO}$, $\text{Nb}_2\text{O}_5/5\text{-ZnO}$ and $\text{Nb}_2\text{O}_5/8\text{-ZnO}$ were measured under 100 mW/cm^2 (AM 1.5G) light illumination by a sunlight simulator, as shown in Figure 5. The photovoltaic performances of the PSC devices (open-circuit voltage V_{oc} , short-circuit current J_{sc} , fill factor FF and PCE) are summarized in Table 1. It was shown that $\text{Nb}_2\text{O}_5/5\text{-ZnO}$ -based PSCs showed the best photovoltaic performance. The morphology and surface coverage of the perovskite thin films were characterized using SEM to further verify the quality of the film. The results are shown in Figure 6. The perovskite film based on $\text{Nb}_2\text{O}_5/5\text{-ZnO}$ exhibited a well-connected morphology in which the cracks between the grain boundaries were obviously reduced compared with those on $\text{Nb}_2\text{O}_5/8\text{-ZnO}$ and $\text{Nb}_2\text{O}_5/3\text{-ZnO}$. This could inhibit the

interface recombination of carriers in these regions and contribute to the observed excellent properties based on Nb₂O₅/5-ZnO.

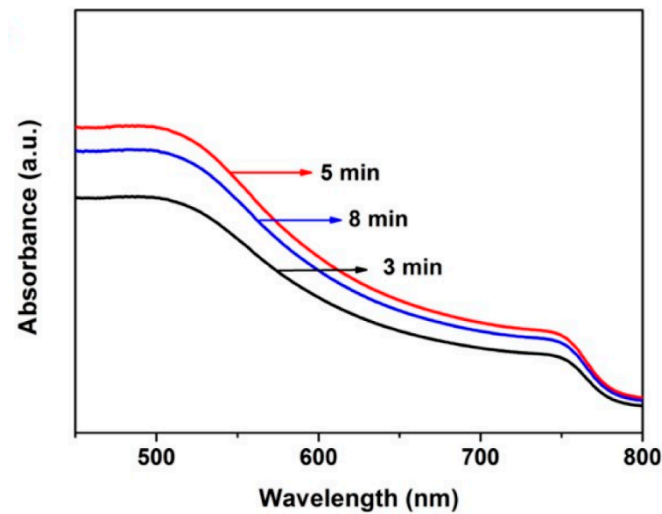


Figure 4. UV-Vis absorption spectra of perovskite films deposited on Nb₂O₅/3-ZnO (3 min), Nb₂O₅/5-ZnO (5 min) and Nb₂O₅/8-ZnO (8 min), respectively.

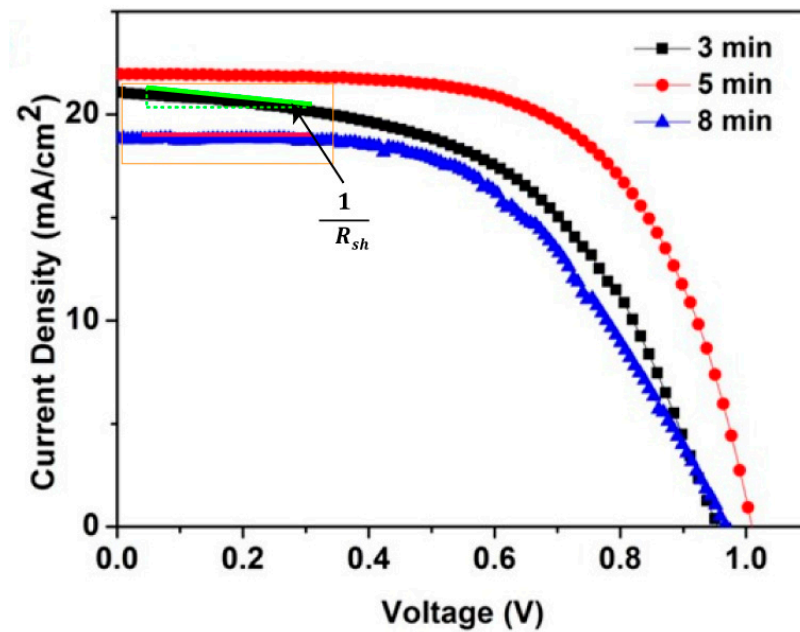


Figure 5. J-V curves of the solar cells based on Nb₂O₅/3-ZnO (3 min), Nb₂O₅/5-ZnO (5 min) and Nb₂O₅/8-ZnO (8 min) under light illumination.

Table 1. Performance parameters of PSCs based on Nb₂O₅ / ZnO films.

Sputter ZnO Time (min)	V _{OC} (V)	J _{SC} (mA/cm ²)	FF (%)	PCE (%)
3	0.94	21.0	52.4	10.5
5	1.0	21.9	62.7	13.8
8	0.97	18.9	53	9.7

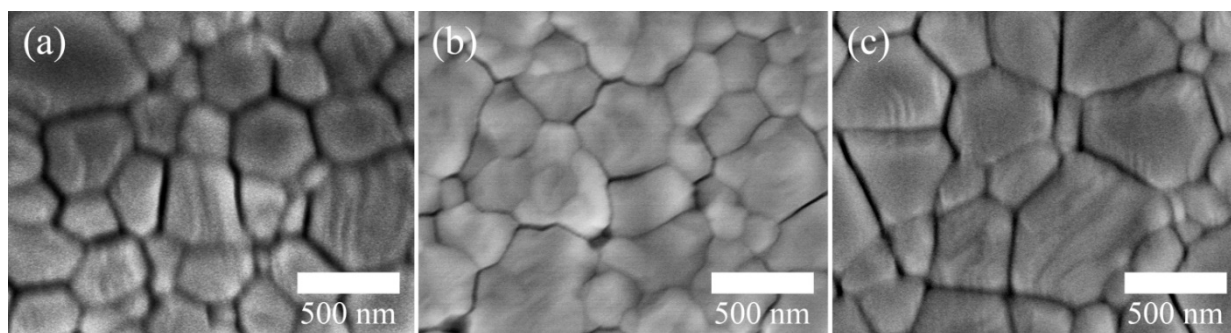


Figure 6. SEM of perovskite films deposited on (a) Nb₂O₅/3-ZnO (3 min), (b) Nb₂O₅/5-ZnO (5 min) and (c) Nb₂O₅/8-ZnO (8 min).

In order to verify the accuracy of J_{SC} in Table 1, the IPCE on these devices was measured. The theoretical values of J_{SC} were extracted from the spectra as shown in Figure S2. The J_{SC} was 20.3 mA/cm², 21.2 mA/cm² and 18.1 mA/cm² based on Nb₂O₅/3-ZnO, Nb₂O₅/5-ZnO and Nb₂O₅/8-ZnO, respectively. It was consistent with the results of the J-V curves, thereby successfully verifying the accuracy of experimental results. Although the absorption property of the perovskite in the case of Nb₂O₅/3-ZnO was the worst, the thinner Nb₂O₅/3-ZnO could lead to less recombination of the carriers and offset a lower light absorption of the perovskite. Therefore, J_{SC} and the IPCE in the case of Nb₂O₅/3-ZnO and Nb₂O₅/5-ZnO are close.

Electrical impedance spectroscopy (EIS) was employed to examine carrier transfer at the interfaces of the perovskite and different ETLs under dark conditions so as to further understand the influence of different ETLs on the photovoltaic properties. Figure 7a shows a Nyquist diagram of PSCs based on Nb₂O₅/3-ZnO, Nb₂O₅/5-ZnO and Nb₂O₅/8-ZnO, which were measured under a 1 V forward bias. The equivalent circuit model is shown in the insert of Figure 7a and is composed of solution resistance (R_s) and charge transfer resistance (R_{ct}). On account of the semblable device structure of the PSCs, the solution resistance (R_s) was almost the same. Three separate semicircles in Nyquist plots were obtained by frequency analysis; the radius of the semicircles represents R_{ct} [39], which could be associated with the perovskite/Nb₂O₅/ZnO interfaces. Apparently, the R_{ct} of the device based on Nb₂O₅/5-ZnO was smaller than that obtained from the devices based on Nb₂O₅/3-ZnO and Nb₂O₅/8-ZnO. This indicated that the PSCs based on Nb₂O₅/5-ZnO had a greater charge collection and transport abilities at the interfaces than the others. To further verify this, steady-state photoluminescence (PL) spectra were used to explore the charge transfer kinetics at the perovskite/Nb₂O₅/ZnO interfaces as shown in Figure 7b. The PL peaks around 770 nm were attributed to the emission from the MAPbI₃ [40]. More significant emission quenching was clearly observed for the device based on Nb₂O₅/5-ZnO compared with the devices based on Nb₂O₅/3-ZnO and Nb₂O₅/8-ZnO. These confirmed that the electron transfer through the perovskite/Nb₂O₅/5-ZnO interface was faster and more effective, which contributed to the best photovoltaic properties. These properties were related to the compact perovskite film and less recombination centers at the interfaces based on Nb₂O₅/5-ZnO.

We would like to mention that although the R_{ct} value of Nb₂O₅/8-ZnO was larger than that of Nb₂O₅/3-ZnO, the fill factor (FF) values were close for Nb₂O₅/3-ZnO and Nb₂O₅/8-ZnO. Based on $FF = FF_0 (1 - R_{se}/R_{sh})$ [41], R_{se} was the series resistance and R_{sh} the shunt resistance. R_{se} was approximately regarded as the charge transfer resistance R_{ct} . This indicated that R_{sh} for Nb₂O₅/8-ZnO was larger than Nb₂O₅/3-ZnO. This could be proved from the J-V curves in Figure 5, in which R_{sh} for Nb₂O₅/8-ZnO was larger than Nb₂O₅/3-ZnO extracted from the slope ($1/R_{sh}$) near the short-circuit current point.

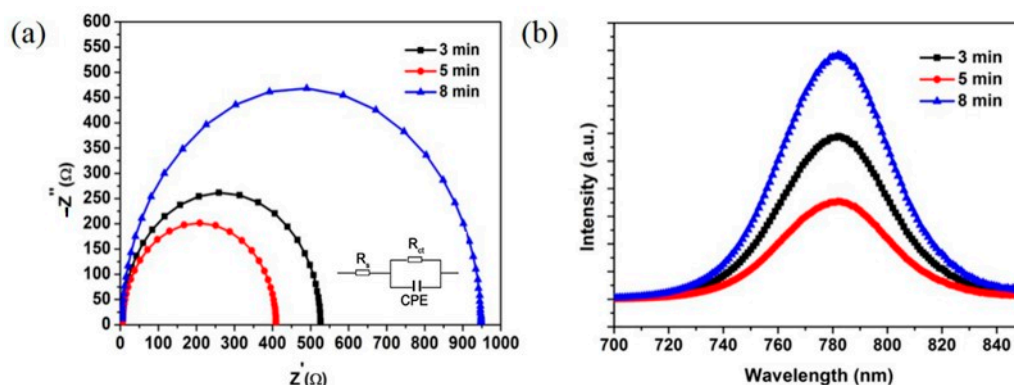


Figure 7. (a) Electrochemical impedance spectroscopy (EIS) Nyquist plots (the inset is the equivalent circuit) based on $\text{Nb}_2\text{O}_5/3\text{-ZnO}$ (3 min), $\text{Nb}_2\text{O}_5/5\text{-ZnO}$ (5 min) and $\text{Nb}_2\text{O}_5/8\text{-ZnO}$ (8 min). (b) Photoluminescence (PL) spectra of the PSCs based on $\text{Nb}_2\text{O}_5/3\text{-ZnO}$ (3 min), $\text{Nb}_2\text{O}_5/5\text{-ZnO}$ (5 min) and $\text{Nb}_2\text{O}_5/8\text{-ZnO}$ (8 min).

It is interesting to observe that the perovskite film quality that influenced the PCEs relied on the deposition time of ZnO (ETL) in the DETLs. The influence of ETL thickness on the PCE was found in a perovskite solar cell based on a Nb-doped TiO_{2-x} film as the ETL as well [37]. Kim et al. argued that the obtained best PCE could be related to the excellent electrical properties of the Nb-doped TiO_{2-x} film for the optimized thickness. We would like to mention that the PCE of the perovskite solar cell based on $\text{Nb}_2\text{O}_5/5\text{-ZnO}$ in the current work was still much lower than that of other reported perovskite solar cells [41]. This indicated that the quality of $\text{Nb}_2\text{O}_5/5\text{-ZnO}$ may still not fulfill the high-quality requirement for an electron transport layer in the perovskite solar cell. For example, a serious recombination of carriers may still exist in $\text{Nb}_2\text{O}_5/5\text{-ZnO}$ or the interfaces between $\text{Nb}_2\text{O}_5/5\text{-ZnO}$ and MAPbI_3 if the crystallization was not excellent. A rough morphology of $\text{Nb}_2\text{O}_5/5\text{-ZnO}$ may influence the crystalline quality of MAPbI_3 and then lead to weak light absorption properties. The best quality perovskite film obtained on a DETL could be related to more complete crystallization of the DETL. This process involves the growth kinetics of thin films and the corresponding deposition procedures (MAPbI_3 and DETL) and mechanisms that call for further investigation. The influence of Nb_2O_5 thickness on the PCE of the PSCs is expected and therefore further investigations are needed to optimize the thickness of this layer. This would significantly deepen our understanding of DETL effects on PCE and promote the application of $\text{Nb}_2\text{O}_5/\text{ZnO}$ films in PSCs.

4. Conclusions

In summary, we have demonstrated room temperature processed $\text{Nb}_2\text{O}_5/\text{ZnO}$ thin films as the DETL used in MAPbI_3 -based PSCs. The planer PSCs based on $\text{Nb}_2\text{O}_5/5\text{-ZnO}$ achieved a PCE of 13.8%. This high device performance was attributed to excellent high-quality perovskite film and a perovskite/ETL interface based on $\text{Nb}_2\text{O}_5/5\text{-ZnO}$ film. In addition, the insertion of Nb_2O_5 in the current work prevented the chemical decomposition of MAPbI_3 caused by contact with ZnO. The improved chemical stability, energy band matching and room temperature processing with relatively high device performance suggested great potential for a DETL of $\text{Nb}_2\text{O}_5/\text{ZnO}$ in large area solar cells and other optoelectrical devices.

Supplementary Materials: The following are available online at <https://www.mdpi.com/2079-4991/11/2/329/s1>, Figure S1: XRD patterns of perovskite films based on $\text{Nb}_2\text{O}_5/3\text{-ZnO}$, $\text{Nb}_2\text{O}_5/5\text{-ZnO}$ and $\text{Nb}_2\text{O}_5/8\text{-ZnO}$, respectively, Figure S2: IPCE spectra and current density of the PSCs based on $\text{Nb}_2\text{O}_5/3\text{-ZnO}$, $\text{Nb}_2\text{O}_5/5\text{-ZnO}$ and $\text{Nb}_2\text{O}_5/8\text{-ZnO}$, respectively.

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